

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	39	(wafer with monocrystalline with cavity)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 15:49
L2	9	(wafer with monocrystalline with (buried adj cavity))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 15:50
L3	9	(wafer with monocrystalline with (buried adj (trench or cavity)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 15:51
L4	9	(wafer with monocrystalline with (buried near (trench or cavity)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 15:51
L5	9	(wafer with monocrystalline with ((bury or burying or buried) near (trench or cavity)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 15:52
L6	81	(wafer with ((bury or burying or buried) near (trench or cavity)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 15:52
L7	4	(wafer with ((bury or burying or buried) adj (trench or cavity))). clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 15:55
L8	64	(wafer with ((bury or burying or buried) adj (trench or cavity)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 15:56
L9	44	(wafer with ((bury or burying or buried) adj (void or cavity)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 15:56

L10	59	(wafer with ((bury or burying or buried) adj (void or cavity or hole)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 15:56
L11	6	(wafer with ((bury or burying or buried) adj (void or cavity or hole))).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 15:57
L12	25	(wafer with ((bury or burying or buried) adj (void or cavity or hole))).ti,ab,clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 15:57
L13	22	(wafer with ((buried) adj (void or cavity or hole))).ti,ab,clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 15:58
L14	54	(wafer with ((buried) adj (void or cavity or hole)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 16:02
L15	12	(wafer with ((buried) adj (void or cavity or hole))) and (monocrystalline with wafer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 16:03
L16	4	(wafer with ((buried) adj (void or cavity or hole))) and (monocrystalline with wafer).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 16:03
L17	5	(wafer with ((buried or sealed) adj (void or cavity or hole))) and (monocrystalline with wafer).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 16:03

L19	39	118 and (cavity near5 (insulating or dielectric or oxide or teos or liner))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:08
L20	1	118 and (cavity near5 (surround or surrounding or surrounded) near5 (insulating or dielectric or oxide or teos or liner))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:10
L21	1	118 and (buried near5 cavity near5 (surround or surrounding or surrounded) near5 (insulating or dielectric or oxide or teos or liner))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:10
L22	1	118 and (buried near5 cavity near5 (cover or covered or covering or surround or surrounding or surrounded) near5 (insulating or dielectric or oxide or teos or liner))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:10
L23	3	(buried near5 cavity near5 (cover or covered or covering or surround or surrounding or surrounded) near5 (insulating or dielectric or oxide or teos or liner))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:11
L24	7	(buried near5 cavity near5 (sidewall or wall or cover or covered or covering or surround or surrounding or surrounded) near5 (insulating or dielectric or oxide or teos or liner))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:12
L25	8	(buried near5 cavity near5 (sidewall or wall or cover or covered or covering or surround or surrounding or surrounded) near5 (inhibiting or insulating or dielectric or oxide or teos or liner))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:12
L26	8	(buried near5 cavity near5 (sidewall or wall or cover or covered or covering or surround or surrounding or surrounded) near5 (inhibit or inhibiting or insulating or dielectric or oxide or teos or liner))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:12
L27	8	(buried near5 cavity near5 (sidewall or wall or cover or covered or covering or surround or surrounding or surrounded) near5 (inhibit or inhibition or inhibiting or insulating or dielectric or oxide or teos or liner))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:12

L28	8	(buried near5 cavity near5 (sidewall or wall or cover or covered or covering or surround or surrounding or surrounded) near5 (inhibit or inhibition or inhibiting or inhibited or insulating or dielectric or oxide or teos or liner))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:13
L29	11	(buried near5 (void or cavity) near5 (sidewall or wall or cover or covered or covering or surround or surrounding or surrounded) near5 (inhibit or inhibition or inhibiting or inhibited or insulating or dielectric or oxide or teos or liner))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:14
L30	209	(buried near5 (void or cavity) near5 (inhibit or inhibition or inhibiting or inhibited or insulating or dielectric or oxide or teos or liner))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:15
L31	39	(buried near (void or cavity) near5 (inhibit or inhibition or inhibiting or inhibited or insulating or dielectric or oxide or teos or liner))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:15
L32	22	(buried adj (void or cavity) near5 (inhibit or inhibition or inhibiting or inhibited or insulating or dielectric or oxide or teos or liner))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:15
L34	4	I30 and (buried adj cavity).clm. and membrane	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:21
L35	3	I30 and (buried adj cavity).clm. and membrane.clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:22
L36	4	I30 and (buried adj cavity) and membrane.clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:22
L37	6	I30 and (buried adj cavity) and membrane	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:23

L38	8	I30 and (buried adj cavity) and (membrane or beam)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:25
L39	68	(buried adj cavity) and (membrane or beam)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:25
L40	4	(buried adj cavity) with (membrane or beam)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:27
L41	4	(buried adj cavity) with (membrane or beam or cantilever)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:28
L42	1	((buried adj cavity) with (membrane or beam or cantilever)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:28
L43	3	((buried adj cavity) and (membrane or beam or cantilever)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/14 17:28